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Non-Uniform Spline Quasi-Interpolation to Extract the Series Resistance in Resistive Switching Memristors for Compact Modeling Purposes

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Abstract: An advanced new methodology is presented to improve parameter extraction in resistive memories. The series resistance and some other parameters in resistive memories are obtained, making use of a two-stage algorithm, where the second one is based on quasi-interpolation on non-uniform partitions. The use of this latter advanced mathematical technique provides a numerically robust procedure, and in this manuscript, we focus on it. The series resistance, an essential parameter to characterize the circuit operation of resistive memories, is extracted from experimental curves measured in devices based on hafnium oxide as their dielectric layer. The experimental curves are highly non-linear, due to the underlying physics controlling the device operation, so that a stable numerical procedure is needed. The results also allow promising expectations in the massive extraction of new parameters that can help in the characterization of the electrical device behavior.

Keywords: resistive random access memories; series resistance; modeling; parameter extraction; quasi-interpolation



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1. Introduction

Advanced mathematics can be applied to solve many engineering problems. In fact, centuries ago, many of the mathematical developments were born to solve specific problems that came up as the different engineering disciplines unfolded. However, many techniques developed currently in the context of research groups of mathematicians do not make their way to the fields of applied physics and of other technical subjects. In fact, a quick overview of the mathematical foundations taught in engineering colleges reveals content created mainly in the 19th century. In this manuscript, we present a multidisciplinary application where a clear and well-defined problem, contextualized in the field of electron devices (in particular, related to Resistive Random Access Memories, RRAMs), can be tackled with techniques based on state-of-the-art approximation theory tools, such as spline-quasi-interpolation and other procedures. These advanced tools come to the rescue when we are faced with complex numerical techniques. One of them is connected to accurate derivative calculation. If, for example, a procedure depends on an accurate derivative determination, a simple numerical calculation might not be enough, mostly if the measured device current curves show strong discontinuities, as is the case here with experimental current-voltage curves in RRAMs whose operation is based upon non-linear physical processes. In order to address the intricacies of the numerical procedure presented in this manuscript, we have proposed, in addition to the approximation theory approach, an algorithm to detect particular curve shapes.

There is currently a great interest in research and development activities devoted to RRAMs. These devices are compatible with conventional technologies in the electronics

industry and present an exciting set of features for applications such as the possibility of being used as entropy sources for random number generation circuits, their suitability for non-volatile memories and their potential for neuromorphic computing circuits, such as hardware neural networks [1–5]. For the fabrication of neuromorphic circuits [1,3,4,6], these devices mimic biological synapses and allow for many compact circuits with lower power consumption than in previous technological approaches.

The experimental characterization of electron devices is essential in electronics. A great number of measurements are needed to extract parameters that describe a certain technology [7–11]. Later on, these parameters can be included in analytical expressions to calculate the device current, capacitances and other representative physical magnitudes that are required for their use in circuit design. The corresponding circuit simulation infrastructure is built upon compact models (a set of analytical expressions and technology-dependent parameters) that describe the devices. The parameter extraction routines and the analytical models can be complex; therefore, as stated above, advanced mathematics have to be employed to deal with modeling problems with guaranties.

In relation to the latter issue, it is important to highlight that several works have been presented on the subject. For instance, in [12], a numerical method based on smoothing splines was proposed to extract the threshold voltage in Metal Oxide Semiconductor Field Effect Transistors (MOSFETs). This method leads to the solution of a system of linear equations whose order increases with the number of intervals of the spline space considered. For this kind of device, a strategy relying on the use of a weighted essentially non-oscillatory method was described in [13]. MOSFET devices operate differently from RRAMs; however, some of the numerical issues that come up in the parameter extraction context are similar. A modeling problem for MOSFETs with a square shape was successfully tackled with advanced partial differential equation methodologies in [14]. For RRAMs, we can highlight the approach followed in [15], where state-of-the-art techniques for derivative calculation were employed.

We present here a mathematical technique to improve the extraction of the series resistance in RRAMs [16–18]. The series resistance is an essential parameter that needs to be obtained to represent the device correctly at the circuit level. A key issue in the corresponding extraction technique lies in the curve slope determination, and this can be performed by means of a derivative calculation. For this purpose, we study current curves (representing the set process of the device, where the device resistance drastically drops off due to the formation of an internal conductive filament) and go on with an in-depth modeling process based on non-uniform spline quasi-interpolation. We have employed related methodologies [19] based on the charge-flux domain; nevertheless, we have to go a step forward in these methodologies to address this new problem due to the strong non-linearity of our devices.

In Section 2, we shortly introduce the engineering problem and some details of the devices employed and measured. Section 3 is devoted to describing the mathematical foundations to deal with the numerical procedures needed. The final results are explained in Section 4, along with the main conclusions.

2. The Problem

The devices analyzed here were fabricated at the Institute of Microelectronics of Barcelona (CNM-CSIC) [18,20,21] and measured in our laboratory at the University of Granada. A scheme of the structures fabricated and measured is shown in Figure 1a. The devices were square-shaped with an area of $15 \times 15 \mu\text{m}^2$. The bottom electrode (Wolfram) was grounded with a titanium layer below. A voltage ramp of (0.08 V/s) was applied to the top electrode (titanium with a TiN layer above) with a voltage step of 0.01 V. Hundreds of curves (resistive switching cycles) were measured in a successive manner. That is why our new technique has to be numerically stable and efficient, in order to be applied to many different current curves. For the measurements employed here, we employed 200 points per

curve. This is reasonable since this means the use of voltage steps in the order of 0.01, where the main features of the devices under study are captured.

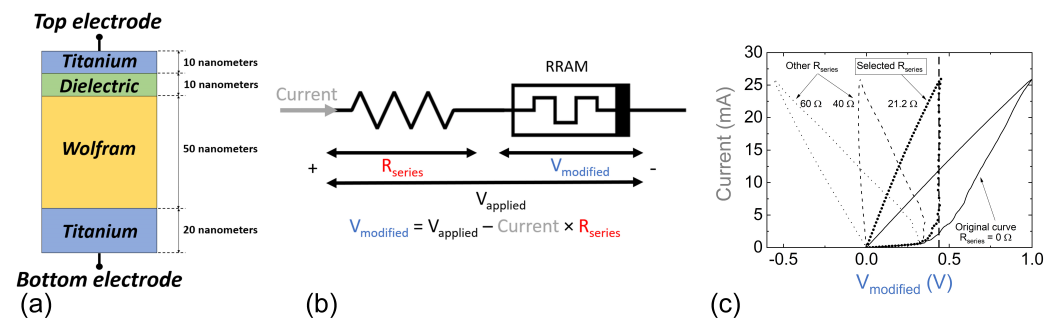


Figure 1. (a) RRAM structure cross-section. (b) Circuit scheme to explain the different voltages employed in this work. (c) Current versus modified voltage for different series resistances. We choose the curve with the maximum slope (in fact, it is a vertical region, shown in symbols) as the one that allows us to extract the correct series resistances, as depicted in [18].

Figure 1c shows an experimentally measured curve and those resulting when the variable corresponding to the X-axis is changed (from $V_{applied}$ to $V_{modified}$). The original applied voltage is corrected by the voltage in the series resistance; i.e., we reduce $V_{applied}$ by a factor calculated as $current \times R_{series}$ (see Figure 1b). When we do so, we obtain a new voltage, $V_{modified}$, the one we employ to replot the current curves for different series resistances (see Figure 1c). Among the set of curves obtained for different series resistances, we select the series resistance corresponding to the curve with the vertical section (plotted with symbols in Figure 1c) [18].

Figure 2 shows several original (black) and modified (red) curves, once the series resistance has been extracted. Observe that when the effects of the series resistance have been eliminated, the current versus modified voltage can show a section of negative slope (just after the V_{TS2} points) [16–18]. We define this new parameter as the turning point of the curve for the region of the negative slope, when the curves turn left in the plot. The threshold set voltage (V_{TS}) is defined as the modified voltage corresponding to the vertical region in the current curve, see Figure 2.

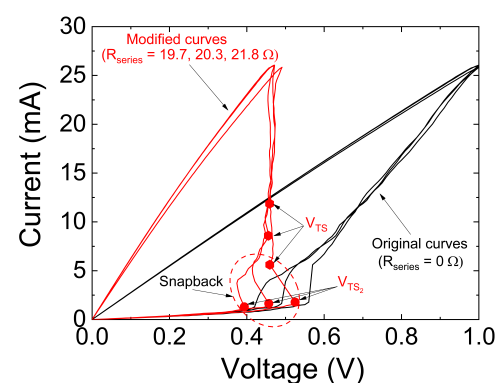


Figure 2. Current versus voltage for some resistive switching cycles. The original measured curves are shown in black, the modified curves in red, the corresponding series resistances are also shown. See the points marked by V_{TS} (threshold set voltages) and V_{TS2} , the points where the slope of the curve changes sign, marked with red dots in the modified curves.

Once the vertical slope is detected and the corresponding series resistance is obtained, the algorithm to extract V_{TS} and V_{TS2} needs a smooth approximant that accurately represents the current-voltage curve.

3. Algorithms Description

Let V_i and I_i be the voltage and current applied, at time t_i , respectively, $i = 0, \dots, n$. We assume here a non-uniform approach because, as a general rule, the measurement instruments do not always provide a uniform set of data. Therefore, for the sake of generality, a non-uniform quasi-interpolation scheme is followed. The proposed procedure for extracting the parameters of interest associated with the curve $V_{\text{applied}} - I$ is structured in two parts. In the first one, a procedure is established that provides the series resistance R_{series} such that the modified data $\{(V_i - R_{\text{series}} I_i, I_i), i = 0, \dots, n\}$ shows a nearly vertical segment. It also provides the set of points that determine that segment. In the second part, the quasi-interpolation spline on non-uniform partitions is used to deal with the modified curve $V_{\text{modified}} - I$ data associated with the series resistance R_{series} in order to extract other parameters of interest.

3.1. Estimating the Series Resistance

In this section, we will propose the algorithm to estimate R_{series} and the threshold set voltage V_{TS} . In the $V_{\text{modified}} - I$ curve, V_{TS} corresponds to a vertical set of data for the value R_{series} [18].

In order to understand the behavior of the $V_{\text{modified}} - I$ curve, firstly, we represent the measured values of a specific cycle (we consider a cycle as a set process followed by a reset process; therefore, the device resistance is changed from high to low and the other way around in each cycle that is repeated many times, 1000 in our case, in what is called a resistive switching series in the RRAM characterization process). A series resistance $R = 0 \Omega$ is applied to obtain the black plot in Figure 3, the original measurements. Then, the initial values are modified with $R = 28.25 \Omega$ to obtain the red plot with symbols. Two other curves are represented, for which $R = 13 \Omega$ (green plot) and $R = 36 \Omega$ (pink plot).

As shown in Figure 3a, the cycle starts and ends at $(0,0)$. We observe that the vertical segment is approximately in the center of the cycle, so that, for our measurements, the beginning and the end of the cycle are neglected [18], around 25% of the data in each part. The admissible part of the cycle will begin at index i_1 , the index of the first point in the 25% limit to end at i_n , and the index of the last point in the 25% limit. The behavior of the curves modified by using a resistance R is quite similar, so this procedure is reasonable, see more details in [18].

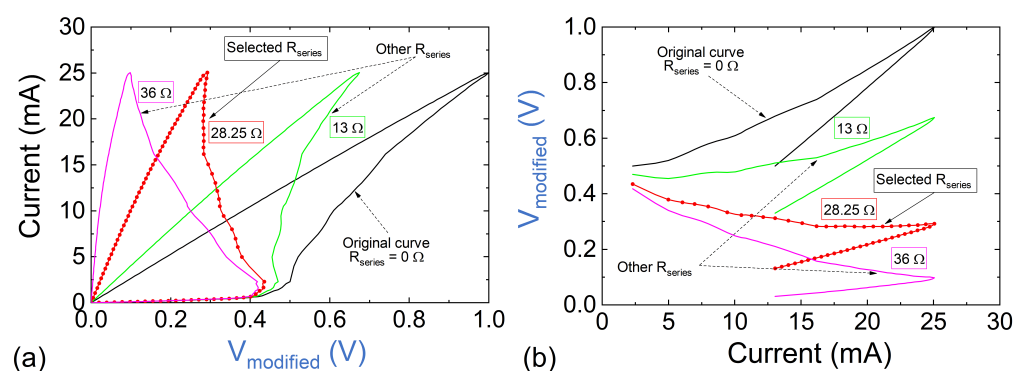


Figure 3. (a) Current versus modified voltage for several series resistances. The selected series resistance corresponds to the curve with the vertical slope, shown with symbols. (b) Modified voltage versus current for the same curves shown on the left. The plots shown are parts of the graphs in (a) with the X-axis and Y-axis exchanged. The curve with the vertical section in (a) presents in this case a horizontal slope, as it is expected. In this manner, the algorithm to extract the series resistance can be applied more easily in (b).

To detect the vertical set of data, we work with $I - V_{\text{mod}}$ curves, where $V_{\text{mod}} := V_{\text{applied}} - R \times \text{Current}$, so we will detect a horizontal set from which R_{series} will result (see Figure 3b). We will consider constant segments formed by, at least, m points, with $m \geq 10$.

To find if a given $I - V_{\text{mod}}$ cycle (with a fixed R value, starting from $R = 0$) has a horizontal subset of data, we compute the least square constant

$$V_{ls_m}(i_1) := \frac{1}{m} \sum_{j=1}^m V_{\text{mod}i_j}$$

for data starting at $(I_{i_1}, V_{\text{mod}i_1})$ and ending at $(I_{i_{m-1}}, V_{\text{mod}i_{m-1}})$, and the least square constant, $V_{ls_{m+1}}(i_1)$, for data starting at $(I_{i_1}, V_{\text{mod}i_1})$ and ending at $(I_{i_m}, V_{\text{mod}i_m})$. Define also $m_{\text{max}} = m$.

Given a tolerance ϵ , and $\bar{V}_{ls}(i_1)$ being the mean value of the computed $V_{ls}(i_1)$ starting at index i_1 , if

$$\max_{m \leq j \leq m_{\text{max}}} |V_{ls_j}(i_1) - \bar{V}_{ls}(i_1)| < \epsilon,$$

then the segment formed by the points indexed i_1 to i_m forms a constant segment within the tolerance ϵ . In this case, we compute V_{ls} ending at the next point i_{m+1} , define $m_{\text{max}} = m + 1$ and check again the tolerance criterion. We end the process when we find a point $i_{m_{\text{max}}+1}$ where the tolerance checking does not hold. Then, we save the starting point $i_{\text{st}}(R)$ and the ending point $i_{\text{end}}(R)$ of the constant segment, increase R by 1 and start again the process of computing the constant segment with the new value of R .

If we have not found a constant segment in the previous process starting with i_1 , we increase this index by 1 and check again for a constant segment. The process ends when we find a constant segment or when the starting point i_i is outside the valid data range, i.e., in the 25% ending data limit.

We stop increasing R when we find negative values of V_{mod} . Now we have an interval $[R_{\text{min}}, R_{\text{max}}]$ of values of R that provide a constant segment of data in the $I - V_{\text{mod}}$ circle (as shown in Figure 3b, for the red curve) within the given tolerance ϵ . We have to select the R value that gives the optimal segment, the “more” constant one.

In order to estimate the optimal value R_{series} of R , we first select the maximal interval $(i_{\text{st}}, i_{\text{end}})$ among all the intervals found for the different values of R we have checked.

For this maximal interval, we will perform a bisection search of the value R_{series} in $[R_{\text{min}}, R_{\text{max}}]$ applied to the mean square error

$$E(R) := \sum_{i=i_{\text{st}}}^{i_{\text{end}}} (V_{\text{mod}i}(R) - V_{ls}(R))^2 \tag{1}$$

to compute the value of R that provides the smallest $E(R)$. In order to achieve that, we compute the values $E(R_{\text{min}})$, $E(R_{\text{max}})$, and we take a new interval $[R_{\text{min}}, R_{\text{max}}]$ as the one with one of the endpoints at the midpoint of the interval $[R_{\text{min}}, R_{\text{max}}]$ and the other endpoint as the value of R_{min} or R_{max} with smaller $E(R)$. We end the bisection process when the length of the interval (or the value $E(R)$) is less than a certain tolerance.

The application of the explained process to the cycle that appears in Figure 3a (with $R = 0$, black curve) provides the resistance $R = 28.25$ (red curve).

The algorithm is summarized, step by step, in the following lines:

1. Take $R = 0$.
2. If any value for $V_{\text{mod}}(R)$ is negative, go to point 12.
3. Take a point $i_{\text{st}} = i_1$ starting 25% from the beginning of the data.
4. Take an ending point $i_{\text{end}} = i_{m-1}$, with fixed $m \geq 10$. If i_{end} is outside the 25% limit, go to stage 11.
5. Compute the mean-square constant $V_{ls_{i_{\text{end}}}}$ that approximates $(I_k(R), V_{\text{mod}k}(R))$ with $k = i_{\text{st}}, \dots, i_{\text{end}}$.
6. Compute

$$E_{\infty} := \max_{i_{m-1} \leq j \leq i_{\text{end}}} |V_{ls_j} - \bar{V}_{ls}|,$$

- where \bar{V}_{ls} is the mean value of the computed V_{ls} starting at index i_1 .
7. If $i_{end} > i_{m-1}$ and $E_\infty < \epsilon$, the data with indexes between i_{st} and i_{end} form a constant segment.
 8. If $i_{end} = i_{m-1}$ or the segment (i_{st}, i_{end}) is constant, increase $i_{end} = i_{end} + 1$ (ending when the value is outside the 25% limit) and go to point 5.
 9. If the segment (i_{st}, i_{end-1}) is constant, but $E_\infty > \epsilon$, for R , the segment (i_1, i_{end-1}) is a potential candidate for the final horizontal segment. Save the values associated with R .
 10. If the segment (i_{st}, i_{end}) is not constant, increase $i_{st} = i_{st} + 1$ (ending when the value is outside the 25% limit) and go to stage 4.
 11. Increase $R = R + 1$ and go to stage 2.
 12. For all the values of R with constant segments, take the reference interval as the greatest one among the saved segment candidates.
 13. Perform a bisection search between R_{min} and R_{max} applied to the mean square error given by Equation (1) to compute the value of R that provides the smallest $E(R)$.

3.2. Non-Uniform Quasi-Interpolating Splines for Parameter Extraction

Once the resistance R that provides the appropriate modified voltages has been determined, the data $\{(V_i - R I_i, I_i), i = 0, \dots, n\}$ should be approximated in order to extract other parameters of interest. The variable change introduced demonstrates the need of the non-uniform approach followed here evident. Therefore, now we propose a general method to construct high-precision spline approximants to a function f defined on an interval $I := [a, b]$, from its values $f(t_i)$ at non-equally spaced points t_i such that

$$a := t_0 < t_1 < t_2 < \dots < t_{n-1} < t_n := b. \tag{2}$$

It will be applied to the voltage and current functions to define approximating splines from their values at times t_i .

Now, we introduce the space where the approximating splines will be defined and recall some results [22,23].

Definition 1. Let $n, d \in N$, and let Δ be a knot sequence satisfying (2). The spline space $S_d(\Delta)$ of order $d + 1$ is the space of all $C^{d-1}(I)$ -piecewise polynomial functions whose restrictions to each sub-interval $[t_i, t_{i+1}], i = 0, \dots, n - 1$ is a polynomial of degree at most d .

It is well-known that $S_d(\Delta)$ is a linear space of dimension $n + d$. To get a good basis of this space, an extended partition is needed. Among all options, we choose the one with multiple end knots (see Figure 4):

$$t_{-d} = \dots = t_{-1} = t_0 < t_1 < t_2 < \dots < t_{n-1} < t_n = t_{n+1} = \dots = t_{n+d}. \tag{3}$$

Figure 4. Extended partition with multiple endpoints.

Proposition 1 ([23] (Th. 4.9)). Let Δ_* be the extended partition given by (3). For $i = 1, \dots, n+d$, let

$$N_{i,d}(t) := (t_i - t_{i-d-1})[t_{i-d-1}, \dots, t_i](\cdot - t)_+^d,$$

where $[z_0, \dots, z_k]g$ and $(\cdot)_+^r$ stand for the divided difference of g at z_0, \dots, z_k and the truncated power of degree r , respectively. Then, $\{N_{i,d}\}_{1 \leq i \leq n+d}$ forms a basis for $S_d(\Delta)$ with

$$N_{i,d}(t) = 0 \quad \text{for } t \notin [t_{i-d-1}, t_i]$$

and

$$N_{i,d}(t) > 0 \text{ for } t \in (t_{i-d-1}, t_i).$$

Moreover,

$$\sum_{i=1}^{n+d} N_{i,d}(t) = 1 \text{ for all } a \leq t \leq b.$$

Since monomials up to the degree d belong to the space $S_d(\Delta)$, they are expressed in terms of the B-splines. These representations are essential to define the approximating splines we want to use to approximate a given function. They are obtained as a consequence of Marsden’s identity [23] (Th. 4.21).

Proposition 2. For any non-negative integer $r \leq d$, the monomial $m_r(t) := t^r$ can be written as a linear combination of the basis of B-splines as follows:

$$m_r(t) = \sum_{i=1}^{n+d} \theta_i^{(r)} N_{i,d}(t), \tag{4}$$

where

$$\theta_i^{(r)} = \binom{d}{r}^{-1} \text{symm}_{r-1}(t_{i-d}, \dots, t_{i-1}), \tag{5}$$

and the classical symmetric functions are

$$\begin{aligned} \text{symm}_0(t_1, \dots, t_p) &= 1, \\ \text{symm}_j(t_1, \dots, t_p) &= \sum_{1 \leq i_1 < i_2 < \dots < i_j \leq p} t_{i_1} t_{i_2} \dots t_{i_j}, \quad 1 \leq j \leq p. \end{aligned}$$

In particular, from (4) and (5), we obtain $\theta_i^{(0)} = 1$ and

$$\theta_i^{(1)} = \frac{1}{d} \sum_{\ell=1}^d t_{i-\ell},$$

so that

$$1 = \sum_{i=1}^{n+d} N_{i,d}(t) \quad \text{and} \quad t = \sum_{i=1}^{n+d} \theta_i^{(1)} N_{i,d}(t).$$

As a consequence, the operator $S : C(I) \rightarrow S_d(\Delta)$ defined as

$$S(f) = Sf = \sum_{i=1}^{n+d} f(\theta_i^{(1)}) N_{i,d}$$

is exact on \mathbb{P}_1 , the space of polynomials of degree less than or equal to 1. That Schoenberg operator provides an approximating spline for f , but only an approximation order equal to $\mathcal{O}(h^2)$ is obtained, where $h := \max_{0 \leq i \leq n-1} h_i$ and $h_i := t_{i+1} - t_i$.

Note that, when the t_i 's are equally spaced values obtained by dividing the interval I into n equal parts, then $t_i = a + i h$ with $h = (b - a)/n$ and

$$\theta_i^{(1)} = a + h \left(i - \frac{d+1}{2} \right), \quad 1 \leq i \leq n+d.$$

Therefore, for an even d , the Greville’s abscissa $\theta_i^{(1)}$ is the mid-point of an interval. However, when d is odd, $\theta_i^{(1)}$ is one of the knots. Since the function to be approximated is

only known at the knots, in the general case, we will consider an odd degree $d = 2k + 1$, $k \geq 1$ and construct operators $Q_d : C(I) \rightarrow S_d(\Delta)$ having the form

$$Q_d(f) = Q_d f = \sum_{i=1}^{n+d} \mu_{i,d}(f) N_{i,d} \tag{6}$$

and yielding an approximation order $\mathcal{O}(h^{d+1})$. This is achieved by imposing the exactness of Q_d on the space \mathbb{P}_d of all polynomials of degree at most d .

Lemma 1. Q_d is exact on \mathbb{P}_d if and only if

$$\mu_{i,d}(m_r) = \theta_i^{(r)}, \quad 0 \leq r \leq d, \quad \text{for all } i = 1, \dots, n + d. \tag{7}$$

Proof. Q_d is exact on \mathbb{P}_d if and only if $Q_d m_r = m_r$, $0 \leq r \leq d$. On the one hand, by (6) it holds that

$$Q_d m_r = \sum_{i=1}^{n+d} \mu_{i,d}(m_r) N_{i,d}.$$

On the other hand, by (4) we have

$$m_r = \sum_{i=1}^{n+d} \theta_i^{(r)} N_{i,d}.$$

Then, $Q_d m_r = m_r$ if and only if $\mu_{i,d}(m_r) = \theta_i^{(r)}$. \square

From now on we will assume that d is odd. For $d + 1 \leq i \leq n$, the B-splines $N_{i,d}$ are supported on $[t_{i-d-1}, t_i]$ (see Figure 5) so that the linear functionals $\mu_{i,d}$ will be determined by the values of f at $d + 1$ knots lying in the support, i.e.,

$$\mu_{i,d}(f) := \sum_{j=0}^d \alpha_{i,j} f(t_{i-d+j}). \tag{8}$$

For $1 \leq i \leq d$, the B-spline $N_{i,d}$ is supported on $[t_0, t_i]$. Then, $d - i + 1$ additional knots are needed to define

$$\mu_{i,d}(f) := \sum_{j=0}^d \alpha_{i,j} f(t_j). \tag{9}$$

Analogously, for $n - d \leq i \leq n - 1$ we define

$$\mu_{i,d}(f) := \sum_{j=0}^d \alpha_{i,j} f(t_{n-d+j}). \tag{10}$$

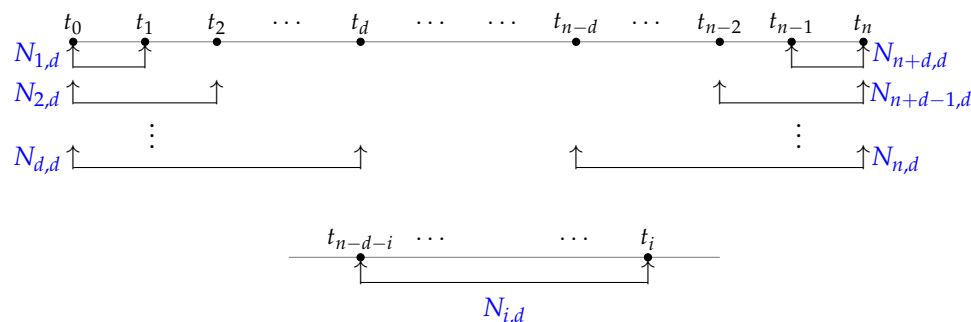


Figure 5. Supports of the B-splines defined on an extended partition with multiple endpoints.

Theorem 1. *There exist unique values $\alpha_{i,j}$ such that the quasi-interpolation Q_d given by (6) and the linear functionals defined by (8)–(10) are exact on \mathbb{P}_d .*

Proof. Let us suppose $d + 1 \leq i \leq n$. By (7), Q_r is exact on \mathbb{P}_d if and only if $\mu_{i,d}(m_r) = \theta_i^{(r)}$, $0 \leq r \leq d$, i.e.,

$$\begin{pmatrix} 1 & 1 & \cdots & 1 \\ t_{i-d} & t_{i-d+1} & \cdots & t_i \\ \vdots & \vdots & \ddots & \vdots \\ t_{i-d}^d & t_{i-d+1}^d & \cdots & t_i^d \end{pmatrix} \begin{pmatrix} \alpha_{i,0} \\ \alpha_{i,1} \\ \vdots \\ \alpha_{i,d} \end{pmatrix} = \begin{pmatrix} \theta_i^{(0)} \\ \theta_i^{(1)} \\ \vdots \\ \theta_i^{(d)} \end{pmatrix}.$$

The Vandermonde matrix of this system of linear equations is non-singular as the involved knots are pairwise distinct. Therefore, the claim follows in this case.

The proof in the case $1 \leq i \leq d$ (resp. $n - d \leq i \leq n - 1$) is similar, but now the linear functional given by (9) (resp. (10)) is involved, so that the matrix of coefficients is of Vandermonde type based on the knots t_0, \dots, t_d (resp. t_{n-d}, \dots, t_n). \square

In the cubic case, for $s + 1 \leq i \leq n$, it holds

$$\theta_i^{(0)} = 1, \theta_i^{(1)} = \frac{t_{i-3} + t_{i-2} + t_{i-1}}{3}, \theta_i^{(2)} = \frac{t_{i-3}t_{i-2} + t_{i-3}t_{i-1} + t_{i-2}t_{i-1}}{3},$$

and $\theta_i^{(3)} = t_{i-3}t_{i-2}t_{i-1}$, and a straightforward calculation leads to the following result on the unique quasi-interpolation operator Q_3 defined from linear functionals based on point evaluations at the knots and yields the optimal approximation order.

Proposition 3. *The coefficients of the unique quasi-interpolation operator Q_3 exact on \mathbb{P}_3 and given by (6), defined by the linear functionals in (8)–(10), are given by the following expressions:*

$$\begin{aligned} \mu_{1,3}(f) &= f(t_0), \\ \mu_{2,3}(f) &= \frac{2h_1(h_1 + h_2) + h_0(2h_1 + h_2)}{3(h_0 + h_1)(h_0 + h_1 + h_2)} f(t_0) + \frac{(h_0 + h_1)(h_0 + h_1 + h_2)}{3h_1(h_1 + h_2)} f(t_1) \\ &\quad - \frac{h_0^2(h_0 + h_1 + h_2)}{3h_1h_2(h_0 + h_1)} f(t_2) + \frac{h_0^2(h_0 + h_1)}{3h_2(h_1 + h_2)(h_0 + h_1 + h_2)} f(t_3), \\ \mu_{k,3}(f) &= \alpha_k f(t_{k-3}) + \beta_k f(t_{k-2}) + \gamma_k f(t_{k-1}), \quad 3 \leq k \leq n + 1, \\ \mu_{n+2,3}(f) &= \frac{2h_{n-2}(h_{n-2} + h_{n-3}) + h_{n-1}(2h_{n-2} + h_{n-3})}{3(h_{n-1} + h_{n-2})(h_{n-1} + h_{n-2} + h_{n-3})} f(t_n) \\ &\quad + \frac{(h_{n-1} + h_{n-2})(h_{n-1} + h_{n-2} + h_{n-3})}{3h_{n-2}(h_{n-2} + h_{n-3})} f(t_{n-1}) \\ &\quad - \frac{h_{n-1}^2(h_{n-1} + h_{n-2} + h_{n-3})}{3h_{n-2}h_{n-3}(h_{n-1} + h_{n-2})} f(t_{n-2}) \\ &\quad + \frac{h_{n-1}^2(h_{n-1} + h_{n-2})}{3h_{n-3}(h_{n-2} + h_{n-3})(h_{n-1} + h_{n-2} + h_{n-3})} f(t_{n-3}), \\ \mu_{n+3,3}(f) &= f(t_n), \end{aligned}$$

with

$$\alpha_k = -\frac{h_{k-1}^2}{3h_{k-2}(h_{k-2} + h_{k-1})}, \beta_k = \frac{(h_{k-2} + h_{k-1})^2}{3h_{k-2}h_{k-1}}, \gamma_k = 1 - \alpha_k - \beta_k.$$

The resulting operator will be used to approximate the voltage-current curves. Note that after solving the system ensuring the exactness of the quasi-interpolation operator,

an approximating spline is immediately available for the function being considered, and no specific system needs to be solved to determine it. Only the values of the function at the knots determine the coefficients of the linear combination of B-splines.

4. Results and Discussion

To show the effectiveness of the proposed procedure to treat experimental data corresponding to the considered non-linear devices, we will make use of two cycles. For the first one, we will apply the algorithm of series resistance extraction that produces a modified set that gives rise to a discrete curve with an almost vertical section. It has provided a resistance of $R = 28.97$ ohms. Both the original and the modified curve are shown in Figure 6a.

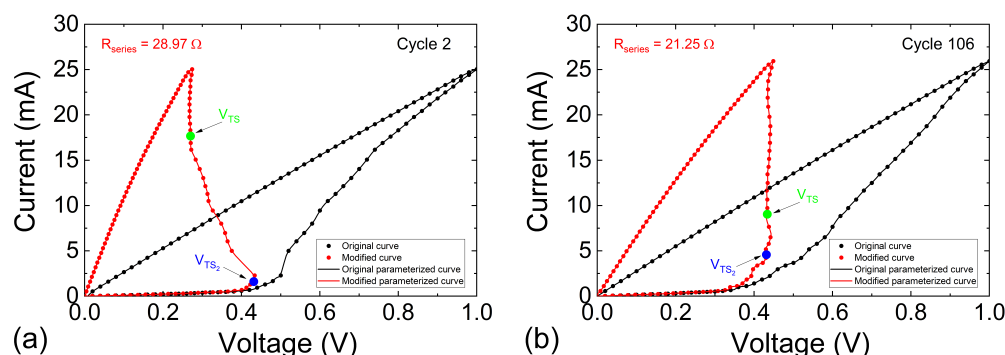


Figure 6. Current versus voltage curves for two different cycles (a) cycle 2 and (b) cycle 106. The original measured curves are shown in black symbols and the modified curves in red symbols. See in lines, with the corresponding colors, the parametrized curves in each case. The V_{TS_2} points are also shown. The cycle numbers correspond to the order of these cycles in the sequence that forms the resistive switching series measured, i.e., cycle 2 consists of the processes employed to change the device resistance for the second time in the series.

For the second cycle (see Figure 6b), the algorithm gives a series resistance equal to $R = 21.25$ ohms.

Therefore, to estimate the points V_{TS_2} shown in Figure 6a, we have taken into account that the modified curves show different regions. At low voltages, the current is low because the conductive filament is not formed; therefore, the curve slope is also relatively low. At the onset of the low resistance state, the conductive filament is formed and there is a sudden current rise, as expected. This constitutes a second region where negative slopes could be seen. The transition of these operation regions is marked by V_{TS_2} . In some cases, the voltage in the series resistance increases considerably, and the modified voltage is reduced, even if the applied voltage goes on increasing.

For each cycle, the C^2 cubic quasi-interpolants QV_{mod} and QI to voltage and current, respectively, are computed. The derivative of I as a function of V is estimated from the derivatives of QI and QV_{mod} as functions of t to yield $\frac{dI}{dV} \simeq \frac{QI'(t)}{QV'_{mod}(t)}$, and the latter is computed to determine the first point at which the slope is negative. It is an estimate of V_{TS_2} . For the cycle considered in Figure 6a, it has been obtained that the slope is negative at $t_\ell = 7.69$ and $V_{TS_2} \simeq (0.43131V, 0.00166A)$. For the one in Figure 6b, $t_\ell = 8.17$ and $V_{TS_2} \simeq (0.43158V, 0.00457A)$. These results are in good agreement with the results shown by the only information available, namely voltages and currents measured at non-uniformly spaced times.

See in Figure 6 that the quasi-interpolant is built correctly both for the original and modified curves. In addition, the vertical section of the curve is correctly detected to extract the corresponding series resistance. For the cycle 2 (resp. 106), the point V_{TS} is attained at $t_\ell = 11.18$ (resp. $t_\ell = 9.48$) and $V_{TS} \simeq (0.27014V, 0.01770A)$ (resp. $V_{TS} \simeq (0.43319V, 0.0089A)$).

5. Conclusions

A new methodology based on an approximation theory approach is presented to deal with the extraction of the series resistance and set transition voltage in resistive memories. A robust procedure is presented in order to develop an algorithm that can be programmed to analyze hundreds of consecutive current-voltage curves in an automatic way.

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